

Form PTO 1449 U.S. Department of Commerce Patent and Trademark Office Information Disclosure Statement by Applicant	ATTY. DOCKET NUMBER HIRA.0204	SERIAL NUMBER 00549683 To be assigned
	APPLICANT SUDA et al.	
	FILING DATE Concurrently Herewith	GROUP

U.S. Patent Documents

Examiner Initial	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE

Foreign Patent Documents

Examiner Initial	DOCUMENT NUMBER	FILING DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
						Yes	No
/MS/	09-181355	12/25/95	Japan			Abstract	X
/MS/	11-145514	11/5/97	Japan			Abstract	X

Other Documents (Including Author, Title, Date Pertinent Pages, Etc.)

		International Search Report for Application Serial No. PCT/JP2004/003689 dated July 6, 2004
/MS/		Norio Onojima et al., "Molecular-Beam Epitaxial Growth of Insulating AlN on Surface-Controlled 6H-SiC Substrate by HCl Gas Etching", Applied Physics Letters, Volume 80, Number 1 (7 January 2002), pp. 76-78.
EXAMINER	/Matthew Song/	DATE CONSIDERED 10/01/2007
EXAMINER: Initial if citation is considered, whether or not citation is in conformance with MPEP 609; draw a line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant		

PTO1449